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Hard ferromagnetism in van der Waals Fe₃GaTe₂ nanoflake down to monolayer

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Two-dimensional (2D) magnetic materials are of not only fundamental scientific interest but also promising candidates for numerous applications. However, so far only a few intrinsic magnets with long-ranged order down to the 2D limit have been experimentally established. Here, we report that the intrinsic 2D ferromagnetism can be realized in van der Waals (vdW) Fe₃GaTe₂ nanoflake down to monolayer. By measuring the Hall resistance and magnetoresistance, we demonstrate that the Fe₃GaTe₂ monolayer exhibits 2D hard ferromagnetism with record-high Cure temperature (T_c) of 240 K for the monolayer of known intrinsic ferromagnets. Both of square-shaped hysteresis loops with near-vertical jump in anomalous Hall effect (AHE) and the negative magnetoresistance (NMR) behavior with an applied out-of-plane magnetic field reveal robust perpendicular magnetic anisotropy (PMA) in Fe₃GaTe₂ nanoflakes down to the monolayer limit. Furthermore, we find the intrinsic mechanism that stems from the Berry curvature of electronic bands dominates AHE of nanoflakes in the low temperature range. Our results not only provide an excellent candidate material for next-generation spintronic applications, but also open up a platform for exploring physical mechanisms in 2D ferromagnetism.

In the past decades, research on two-dimensional (2D) materials has attracted great research interest due to their physical properties and potential applications¹⁻¹⁰. In particular, the recent discovery of 2D magnetic materials, which present intrinsic ferromagnetic/antiferromagnetic ground states at finite temperatures down to atomic-layer thicknesses, offers possibilities for both fundamental research and the potential applications of spintronic devices⁸⁻¹¹. Layered van der Waals bulk magnetic materials facilitate their atomic-layer cleavability and magnetic anisotropy, providing an ideal platform for theoretically and experimentally exploring quantum phenomena in the 2D limit. Unfortunately, finding suitable vdW materials and producing atomically thin magnetic materials have been a challenge. Up to now, there have been only a few reports of producing atomically thin samples of magnetic materials and the observation of magnetic ordering in the 2D limit, such as FePS₃⁸, CrI₃⁹, and so on. However, the magnetic transition temperature of these 2D materials is much lower than room temperature, which limits their practical application. Hence, it is necessary to explore more 2D magnetic materials to achieve higher magnetic transition temperatures.

Among layered vdW magnetic materials, Fe_NGeTe_2 (N = 3, 4, 5) family is particularly remarkable due to its high Curie temperature and vast tunability of magnetic properties^{11–20}. 2D ferromagnetism has been observed in Fe_3GeTe_2 and Fe_5GeTe_2 nanoflakes^{11,12,20}. Recently, a vdW intrinsic ferromagnetic crystal Fe_3GaTe_2 , which has the same structure as Fe_3GeTe_2 , was reported to exhibit record-high Curie temperature (350–380 K) for known layered vdW intrinsic ferromagnets²¹. The robust large perpendicular magnetic anisotropy (PMA) and high Curie temperature are beneficial for experimentally exploring magnetic properties down to the 2D limit. Aboveroom-temperature Curie temperature has been observed in Fe_3GaTe_2 nanoflakes with the thickness of 9.5 nm²¹. Therefore, it is highly anticipated whether its monolayer sample can maintain ferromagnetism and achieve above-room-temperature Curie temperature.

In this work, we have successfully prepared Fe_3GaTe_2 nanoflakes with thickness ranging from bulk to monolayer. As corroborated by Hall resistance and magnetoresistance measurements, all samples present hard ferromagnetism at low temperature. Strikingly, the Fe_3GaTe_2 monolayer exhibits 2D hard ferromagnetism with record-high Curie temperature (T_c)

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of 240 K for known intrinsic vdW ferromagnetic single layer. Square-shaped hysteresis loops with near-vertical jump in AHE and the NMR behavior with an applied out-of-plane magnetic field have been observed, suggesting robust PMA in Fe_3GaTe_2 nanoflakes. Our results compensate for the unexplored electronic and magnetic properties of Fe_3GaTe_2 down to the 2D limit and open up opportunities for next-generation spintronic applications.

Results

Magnetic properties of Fe₃GaTe₂ single crystal

Fe₃GaTe₂ crystallizes in a hexagonal structure (space group P6₃/mmc), which consists of layered building blocks stacking along the *c*-axis²¹. As shown in Fig. 1a, each of these blocks contains two layers of Te atoms and a Fe-Ga slab with two different Fe atom sites (Fe1 and Fe2) sandwiched between the two Te layers. The van der Waals (vdW) gap between two adjacent blocks makes crystals cleavable. In this work, we define one such block as one vdW layer (a monolayer, 1 L, with a thickness of ~ 0.8 nm) for Fe₃GaTe₂; thus, one unit cell is composed of two layers (2 L). The plate-like Fe₃GaTe₂ single crystals with the typical size of $2 \times 2 \times 0.1$ mm³ were grown via a self-flux method. A detailed growth procedure is described in the methods section. The X-ray diffraction (XRD) of as-grown Fe₃GaTe₂ bulk crystals is displayed in Supplementary Fig. 1. Only (00 l) peaks are observed, implying the strict orientation growth and high crystallinity. The calculated c-axis lattice parameter is 16.19 Å, consistent with previous reported results²¹. The chemical compositions of these crystals were identified by the energy dispersive spectroscopy (EDS), revealing the averaged atomic ratio as Fe : Ga : Te = 3.05 : 0.97 : 2 (Supplementary Table 1), in good agreement with the stoichiometric ratio.

Figure 1b displays the temperature-dependent magnetization (M-T) measurements performed with zero-field-cooling (ZFC) and field-cooling (FC) conditions under an applied magnetic field of 0.1 T. The single crystals show a typical ferromagnetic feature and the Curie temperature (T_c) estimated by the maximum of |dM/dT| is about 340 K (Supplementary Fig. 1b), which is consistent with recent reports²². Over the entire temperature range from 2 to 300 K, the magnetization for H//c is much larger than that of H//ab, indicating a perpendicular magnetic anisotropy (the *c*-axis is the easy-magnetization axis). A clear split is observed on the ZFC and FC curves at low temperature, which is a characteristic behavior of ferromagnets and implies the formation of a multi-domain magnetic structure²³. Figure 1c

shows the isothermal *M*–*H* curves measured for Fe₃GaTe₂ single crystals at the temperature range from 2 to 400 K between -5 T and 5 T. Solid and dashed lines are data for *H*// *c* and *H*// *ab*, respectively. Typical magnetic hysteresis loops are observed when the magnetic field is along the out-of-plane orientation (*H*// *c*), while vanish under the in-plane orientation (*H*// *ab*), further suggesting the out-of-plane magnetic anisotropy in bulk Fe₃GaTe₂. It should be noted that *M*–*H* curves for *H*// *c* exhibits a relatively large coercivity field ($H_c \sim 110 \text{ mT}$) at 2 K, implying hard ferromagnetism in bulk samples. In addition, the saturation magnetization (M_s) of Fe₃GaTe₂ bulk crystal decreases with increasing temperature, but it drops slowly below 150 K (Supplementary Fig. 1c).

Characterization of Fe₃GaTe₂ nanoflakes

To investigate the thickness-dependent magnetic properties, we fabricated devices with Hall bar configurations based on atomically thin Fe₃GaTe₂ thin flakes. Since it is difficult to obtain ultrathin flakes using the conventional scotch tape method, we utilized the previously reported Al₂O₃-assisted exfoliation technique^{11,24,25} and successfully obtained sizable thin flakes with thickness approaching to the 2D limit. A detailed device preparation procedure is described in the methods section. Figure 2a and Supplementary Fig. 2a, c show the optical transmission image of few-layer Fe₃GaTe₂ flakes exfoliated by an Al₂O₃ film on top. The whole stack is attached to a piece of transparent polydimethylsiloxane (PDMS) film. Regions with different layer numbers (1 L, monolayer; 2 L, bilayer; 3 L, trilayer; 4 L, four-layer; 5 L, five-layer; 6 L, six-layer) are marked out. In this work, the thickness of ultra-thin Fe₃GaTe₂ nanoflakes can be determined by combination of atomic force microscopy (AFM) and optical transmission measurements (Supplementary Fig. 2), and thick flakes are identified just by AFM measurements (Supplementary Fig. 3b). The optical transmission is defined as $T = G_{sample}^{T}/G_{substrate}^{T}$, where G_{sample}^{T} and $G_{substrate}^{T}$ are the transmission intensities of the sample (Fe₃GaTe₂ nanoflakes) and the substrate (PDMS and Al₂O₃ films). As shown in Fig. 2b, the relationship between the optical transmission and the flake thickness for three different samples all follow the Beer-Lambert law: $\log(T) = 1 - K \times (layer)$ number), where K is the absorption coefficient¹¹. Therefore, the layer number can be determined precisely by the optical transmission. Moreover, the layer identification was also corroborated by atomic force



Fig. 1 | Crystal structure and magnetic properties of Fe₃GaTe₂ single crystal. a Schematic diagram of the crystal structure of Fe₃GaTe₂. b Temperature-dependent magnetization of Fe₃GaTe₂ single crystal measured with $\mu_0 H = 0.1$ T applied within

ab-plane and along *c*-axis in both ZFC and FC modes. **c** M-H curves measured at various temperatures between -5 and 5 T for Fe₃GaTe₂ bulk crystal. Solid and dashed lines are data for H // c and H // ab, respectively.



Fig. 2 | **Characterization of Fe₃GaTe₂ nanoflakes. a** A typical optical transmission image of few-layer Fe₃GaTe₂ flakes exfoliated on top of Al₂O₃ film supported on a piece of transparent polydimethylsiloxane (PDMS) substrate. Regions with different layer numbers (2L-6L) are marked out. Scale bar: 50um. **b** Optical transmission as a function of the layer number. The values of transmission marked by purple squares are extracted from Fig. 2a (sample #1), the red dots are extracted from sample #2 (Supplementary Fig. 2a), and the yellow stars are extracted from sample #3 (Supplementary Fig. 2c) whose thickness has been checked by atomic force microscopy

measurements (Supplementary Fig. 2e, f). Both of them follow the Beer-Lambert law (mauve straight line). **c** A representative optical image of the device with the Fe₃GaTe₂ nanoflake. I+ and I- label the current electrodes, and V₁, V₂, V₃ and V₄ label the voltage probes. Scale bar: 50um. **d** The evolution of the temperature-dependent longitudinal resistance R_{xx} for Fe₃GaTe₂ flakes with different thicknesses. Resistances are normalized by their values at T = 300K. **e** Normalized Hall resistance $R_{xy}(H)$ curves at 2 K for samples with different thicknesses.

microscope (AFM) measurements. The 0.8 nm and 3.2 nm steps in the height profiles exactly match the 1 L and 4 L thicknesses for Fe₃GaTe₂ flakes (Supplementary Fig. 2e, f). An optical image of the typical device based on Fe₃GaTe₂ flake is illustrated in Fig. 2c. The six-probe configuration facilitates us to simultaneously measure the longitudinal resistance (R_{xx}) and Hall resistance (R_{xy}) . Figure 2d shows the temperature-dependent normalized longitudinal resistance $[R_{\rm vx}/R_{\rm vx}(300 {\rm K})]$ for the Fe₃GaTe₂ samples with thicknesses varying from bulk to monolayer. The bulk crystal exhibits a typical metal behavior. As the thickness decreases, the longitudinal resistance (R_{xx}) of the thin flake gradually increases rapidly at low temperature. Unlike other samples, the monolayer sample exhibits semiconductor-like behavior, which may be caused by the electron localization and interaction effects in 2D disordered system²⁶⁻²⁸ (see Supplementary Note 1). It should be pointed out that the upturn of low-temperature resistance in monolayer and bilayer flakes can be well depicted by the 2D Mott variable-range-hopping (VRH) model yielding $\ln(R_{xx}) \sim T^{-1/3}$ (see Fig. 4b). Similar behaviors have been reported in other vdW ferromagnetic thin flakes, such as Fe₃GeTe₂^{29,30} and Fe₅GeTe₂²⁰.

Anomalous Hall effect in Fe₃GaTe₂

As shown above, Fe₃GaTe₂ bulk crystal exhibits hard ferromagnetism. It is generally believed that in ferromagnets, the total Hall resistance R_{xy} can be expressed as $R_{xy} = R_{xy}^0 + R_{xy}^A = R_0\mu_0H + R_sM$, where R_{xy}^0 and R_{xy}^A are the normal and anomalous Hall resistance respectively, and R_0 and R_s are the ordinary and anomalous Hall coefficients, respectively^{31,32}. Since R_{xy}^A scales with magnetization (*M*), it is suitable to study the evolution of magnetism with thickness in Fe₃GaTe₂ nanoflakes by measuring the anomalous Hall resistance. Figure 3 presents the temperature-dependent Hall resistance R_{xy} for Fe₃GaTe₂ with various

thicknesses. The $R_{xy}(H)$ curves at low temperature for all exfoliated thin flakes exhibit sizable square-shaped hysteresis loops with near-vertical jump, which is the hallmark of hard ferromagnetism with singledomain structure. However, the bulk crystal displays a step-like hysteresis loop. When the applied magnetic field sweeps from the positive saturation field to the negative saturation field, the R_{xy} value first drops sharply and then decreases slowly. This behavior generally tracks the M-H curves, suggesting a multi-domain structure. Such a large difference of $R_{xy}(H)$ curves between thin flakes and bulk crystal may be attributed to the thickness-dependent magnetic domain transformation^{12,15}. Similar result has been observed in previously reported Fe₃GaTe₂ nanosheets with different thicknesses²¹.

In particular, we selected the $R_{xy}(H)$ curves at 2 K and normalized them to explore the evolution of the coercivity field (H_c) with thickness, as shown in Fig. 2e. Inspiringly, a sizable hysteresis loop centered at H = 0 with remarkable remanence can be observed in monolayer sample, suggesting intrinsic 2D ferromagnetism in the Fe3GaTe2 monolayer. Such observation is complemented by the magnetoresistance (MR) measurements (Supplementary Fig. 5). At low temperature, a bow-tie shaped hysteresis loop has been observed in all samples with various thicknesses, suggesting distinct ferromagnetism even down to the 2D limit. In addition, since the increase of magnetic field applied along the easy axis can reduce the electron-spin scattering^{20,33}, the negative magnetoresistance (NMR) behavior with applied out-of-plane magnetic field also implies robust PMA in Fe₃GaTe₂ nanoflakes. In order to further validate this issue, we performed angulardependent Hall resistance (R_{xy}) measurements at 20 K for Fe₃GaTe₂ monolayer sample. As shown in Supplementary Fig. 6, with the decrease of θ_H from 90° (*H* // *c*) to 0° (*H* // *ab*), the R_{xy} changes from an uptrend to a downtrend in the high filed regime ($\mu_0 H > 1.5$ T), and the coercive field (H_c)



Fig. 3 | Anomalous Hall effect in Fe₃GaTe₂. Hall resistance R_{xy} at various temperatures measured for Fe₃GaTe₂ thin flakes with different thicknesses (1L-64L) and bulk crystal. External magnetic field *H* is applied along *c*-axis. The scale bars denote the amplitude of Hall resistance for each device.

increases simultaneously. Such behavior is characteristic of ferromagnets with PMA^{11,21,29}. In addition, we also extracted the R_{xy} value at $\mu_0 H = 3$ T to calculate θ_M (the angle between magnetization and the basal plane) by using the formula¹¹: $\theta_M(\theta_H) = \arcsin\left[\frac{R_{xy}(\theta_H)}{R_{xy}(\theta_H = 90^\circ)}\right]$ The calculation result is $\theta_M(\theta_H = 30^\circ) \approx 56^\circ$, and $\theta_M > \theta_H$ also indicates a strong out-of-plane magnetic anisotropy in the monolayer Fe₃GeTe₂. The size of hysteresis in $R_{xy}(H)$ curves shows systematical dependence on thickness. The evolution of H_c with thickness in Fe₃GaTe₂ nanoflakes at 2 K is summarized in Supplementary Fig. 1d, revealing a very pronounced layer dependence of the coercivity field from 78 mT (bulk) to 1.2 T (2 L) at 2 K. For samples with thickness exceeding two layers, the coercivity field decreases monotonically with the increasing layer number, which is consistent with previous report²¹. Nevertheless, the coercivity field of monolayer sample shows a slight decrease compared to bilayer sample. Meanwhile, the square-shape jump of Hall resistance in the monolayer sample is not as sharp as that for other thicknesses, which may be attributed to the disorder in 2D limit.

Thickness-dependent ferromagnetism in Fe₃GaTe₂

In order to investigate the effect of thermal fluctuations on ferromagnetism, we look into the thickness dependence of the Curie temperature T_c . In general, the T_c value can be calibrated by examining the remanent Hall resistance at zero external magnetic field, $R_{xy}^r = R_{xy}(\mu_0 H = 0)$, which is proportional to the zero-field spontaneous magnetization $M(\mu_0 H = 0)$. In this way, T_c is defined as the temperature at the onset of non-zero R_{xy}^r (Supplementary Note 2). Supplementary Fig. 7c shows thickness-temperature phase diagram based on analysis of R_{xy}^r , exhibiting a bizarre dome-like behavior. This result is similar to previously reported Fe₃GeTe₂¹², which can be understood as a temperature-driven magnetic domain formation in thick samples. That is to say, the T_c value determined by the onset of non-zero R_{xy}^r contains the influence of the magnetic domain wall formations. Hence, in this work we tend to define the T_c of Fe₃GaTe₂ thin flakes based on analysis of the Arrott plot of the AHE (see Supplementary Note 3 and Supplementary Fig. 8). The T_c value is determined by extrapolating

high-field data where domains are fully aligned, which minimizes the effects of domain wall formation³⁴. Arrott plots analysis reveal that T_c decreases monotonically as the samples are thinned down from 5 L to 1 L, whilst it barely changes for thickness above 15 L, as shown in Fig. 4a. This large drop in T_c near the 2D limit roughly follows a universal scaling law of ultrathin magnetic films³⁵. Surprisingly, the monolayer still maintains a relatively high T_c (~240 K), record-high for known intrinsic vdW ferromagnetic monolayer^{9,11,12,20}.

Scaling analysis of the anomalous Hall effect

In addition, we also analyze the dominant mechanism of AHE in Fe₃GaTe₂ ultra-thin flakes. It is generally accepted that there are three main mechanisms which contribute to AHE: one is intrinsic AHE that stems from the Berry curvature of electronic bands, the other two are extrinsic mechanisms, named as skew scattering and side jump, respectively³¹. Here, we use the scaling model³⁶ as followed to describe the AHE:

$$R_{xy}^{A}(T) = \left(\alpha R_{xx0} + \beta R_{xx0}^{2}\right) + b R_{xx}^{2}(T)$$
(1)

Since the resistivity of our thin flake is difficult to calculate precisely, we perform a scaling analysis based on the resistance values. In this model, R_{xx0} is the residual resistance, R_{xx} denotes the longitudinal resistance, the coefficients α , β indicate the amplitudes of the AHE terms contributed by two extrinsic mechanisms, skew scattering and side jump, whereas, *b* determine the intrinsic mechanism. In our measurements, $R_{xy}^A \gg R_{xy}^0$, $R_{xx} \gg R_{xy}$, thus, the anomalous Hall conductance (AHC) G_{xy}^A and the longitudinal conductance G_{xx} can be expressed as

$$G_{xy}^{A} = \frac{R_{xy}^{A}}{\left(R_{xy}^{A}\right)^{2} + \left(R_{xx}\right)^{2}}$$
(2)

$$G_{\rm xx} = \frac{R_{\rm xx}}{\left(R_{\rm xy}^{\rm A}\right)^2 + \left(R_{\rm xx}\right)^2} \approx \frac{1}{R_{\rm xx}}$$
(3)



Fig. 4 | Thickness-dependent ferromagnetism in Fe₃GaTe₂. a Phase diagram of Fe₃GaTe₂ thin flakes showing the dimensionality effect of the magnetism. The Curie temperature T_c is determined for each layer number by analysis of the Arrott plot of the AHE (Supplementary Fig. 8). The error bars represent uncertainties in defining the onset temperature of non-zero R_{xy}^{s} . The bottom of the error bar represents the temperature that R_{xy}^s starts to be greater than zero, while the top of the error bar represents the temperature that R_{xy}^s begins to be less than zero. **b** ln (R_{xx}) measured in the monolayer and bilayer (the inset) Fe₃GaTe₂ devices as functions of $T^{-1/3}$. Straight lines denote fits using the 2D Mott variable-range-hopping model:

Equation 1 can also be written in the form of conductance consequently:

$$G_{xy}^{A}(T) = \left(\alpha G_{xx0}^{-1} + \beta G_{xx0}^{-2}\right) G_{xx}^{2}(T) + b \tag{4}$$

We note that the saturation magnetization (M_s) of bulk sample decreases slowly below 150 K, but falls drastically above 150 K (Supplementary Fig. 1c). In order to reduce the interference of the varying M_s on the scale analysis, we just extract the values of R_{xx} and R_{xy} below 150 K in our nanoflakes for scaling analysis, assuming that M_s is essentially constant in this temperature range. In Supplementary Fig. 9, we show the temperaturedependent normalized anomalous Hall resistance R_{xy}^A and anomalous Hall conductance G_{xy}^{A} for Fe₃GaTe₂ thin flakes with thicknesses from 1 L to 5 L. When the temperature is below 60 K, the G_{xy}^{A} of 1 L to 5 L flakes is almost independent of the temperature. We focus on the scaling model Eq. 4, the G_{xy}^{A} versus G_{xx} plot is shown in Fig. 4c. It is noticeable that there is a constant part for G_{xv}^A which is independent of G_{xx} and temperature below 60 K for all nanoflakes with thicknesses from 1 L to 5 L, which points towards the dominance of the intrinsic AHE. Similar results have been observed in Fe₃GaTe₂ nanosheets with thicknesses of 27.2 nm and 10 nm below 100 K in a recent study³⁷. These results all indicate that the AHE in Fe₃GaTe₂ at low temperature arises from an intrinsic mechanism. Furthermore, in the R_{xx}^{A} versus R_{xx}^2 plot (Fig. 4d), the apparent linear behavior of the lowtemperature region also confirms the contribution of the intrinsic AHE³⁸,

8 2.1 (10⁵Ω²) 1.8 2.4 1.2 1.3 1.4 1.5 R_{xx}^2 (10⁴ Ω^2) $\ln(R_{xx}) \sim T^{-1/3}$. c Anomalous Hall conductance G_{xy}^A plotted against the longitudinal conductance G_{xx} for Fe₃GaTe₂ thin flakes with thicknesses between 2 L and 5 L. Inset displays the monolayer case. Along the direction of the grey dotted line, the temperatures from low to high in turn are 2, 10, 20, 40, 60, 80, 100, 125, 150 K. **d** Anomalous Hall resistance R_{xx}^A as a function of R_{xx}^2 in few layer samples (2L-5L). The inset showcases R_{xx}^A vs R_{xx}^2 for the monolayer device. Apparent linear behavior can be seen in the low-temperature region. Along the direction of the grey dotted line, the temperatures from low to high in turn are 2, 10, 20, 40, 60, 80, 100 K. Almost all kinks in (c) and (d) are about 60 K.

T (K)

4.74 $\ln(R_{xx})$ (a.u.

4 72

0.6

2 K

 $T^{-1/3}$ (K^{-1/3})

0.4

3

21

0.7

0.6

2

0.8

0.8

51

5

1L

according to Eq. 1. In particular, we find a significant decrease in the slope of the low-temperature linear part in monolayer compared to the other layers. The intrinsic AHE dramatically decreases as the thickness reaches the 2D limit, indicating that the size effect may change the Berry curvature contribution³⁹. Almost all kinks in the $G_{xy}^A - G_{xx}$ and $R_{xy}^A - R_{xx}^2$ curves are around 60 K. Above 60 K, G_{xy}^A versus G_{xx} appears to be linear and the intrinsic mechanism does not dominate the AHE. The emergence of these kinks seems to be related to the nonmonotonic $R_{xx}(T)$ and similar results have been observed in the high pressure-modulated Fe₃GeTe₂⁴⁰. Our results just reveal that the intrinsic mechanism dominates the AHE of 2D Fe₃GaTe₂ at low temperature and further investigations are required to clarify the mechanism.

Discussion

In summary, we systematically investigated the layer-number dependent magnetic properties in Fe3GaTe2 down to 2D limit by analyses of MR and AHE. Strikingly, the Fe₃GaTe₂ monolayer exhibits a true 2D hard ferromagnetism with a record-high T_c of 240 K for known intrinsic vdW ferromagnetic single layer. Square-shaped hysteresis loops in AHE and the NMR behavior with a magnetic field applied along c-axis have been observed in atomically thin flakes, indicting robust PMA in Fe₃GaTe₂ nanoflakes down to the monolayer limit. Besides, we find the intrinsic mechanism that stems from the Berry curvature of electronic bands dominates AHE of nanoflakes in low-temperature range based on the scaling analysis in ultra-thin films. Our results compensate for the undiscovered electronic and magnetic properties of Fe₃GaTe₂ in the 2D limit, providing a reference for practical applications of next-generation spintronic devices and opening up a platform for exploring physical mechanisms in high-temperature 2D ferromagnetism.

Methods

Crystal growth and characterizations

High-quality bulk Fe₃GaTe₂ single crystals were grown via a self-flux method²¹. High-purity Fe powders (Aladdin, 99.95%), Ga lumps (Aladdin, 99.999%), and Te powders (Aladdin, 99.999%) were mixed in the molar ratio of Fe : Ga : Te = 3 : 1 : 2 in an argon-filled glove box and loaded into a guartz tubes. The sealed guartz tubes were placed into a muffle furnace. It was first heated to 1000°C and held for 3 days for solid reactions. Then the temperature was quickly decreased down to 900°C and slowly cooled down to 800°C in 5 days, followed by slowly cooled down to room temperature. The shiny plate-shaped Fe₃GaTe₂ single crystals with a typical size of 2 mm×2 mm×0.1 mm were selected from the ingot (Supplementary Fig. 1a inset). The crystallographic phase of these single crystals was characterized using room-temperature X-ray diffraction (XRD) measurements (SmartLab-9, Rigaku Corp.) with Cu K α radiation ($\lambda = 1.5406$ Å) (Supplementary Fig. 1a), and the actual chemical compositions were identified by the energy dispersive spectroscopy (EDS) at different microregions on the fresh cleavage surfaces of the same single crystal. Supplementary Table 1 shows the mole ratio of 5 random microregions on one of these samples, and the averaged mole ratio was revealed as Fe: Ga: Te = 3.05: 0.97: 2, which almost consisted with the stoichiometric ratio.

Devices fabrication

The Fe₃GaTe₂ thin flakes with thickness above 12 nm (\approx 15 L) were mechanically exfoliated from the plate-like bulk single crystals using the scotch tape and the polydimethylsiloxane (PDMS) film, and were transferred onto the surface of 300 nm thick SiO₂ insulating layer grown on a highly doped Si substrate. However, ultrathin flakes of Fe₃GaTe₂ (1-5 L) were obtained by the previously developed Al₂O₃-assisted exfoliation technique^{11,20}. In this process, we first deposited an Al₂O₃ thin film onto the prepared fresh cleavage surface of the bulk crystal, then used a thermal release tape to peal the Al₂O₃ film with Fe₃GaTe₂ flakes attached. Scotch tapes were then utilized to exfoliate the Fe₃GaTe₂/Al₂O₃ stack repeatedly until Fe₃GaTe₂ thin flakes with suitable size and thickness appeared. After that, the Fe₃GaTe₂/Al₂O₃ stack was released onto a piece of PDMS film by heating the tape. Since the PDMS and Al₂O₃ films are almost transparent, we can use the transmission mode of the optical microscope to determine the sample thickness before transferring the flakes onto a SiO₂/Si substrate. In this work, the layer number of Fe₃GaTe₂ below 5 was calibrated by the combination of atomic force microscopy (AFM) and the Beer-Lambert law describing the relationship between optical transmission and thickness, whereas the layer number above 15 was determined just via atomic force microscope (AFM) thanks to the low recognition of the Beer-Lambert law in high thickness intervals. Supplementary Fig. 3b shows an AFM scan image of one microregion in the optical picture (Supplementary Fig. 3a), which indicates the thickness of this flake is approximately 12 nm (≈15 L). After transferring the Fe₃GaTe₂/Al₂O₃ stack from a PDMS film onto the substrate, Cr/Au (10/120 nm) electrodes were deposited on flakes using stencil masks for transport measurements. It's worth noting that the flakes with different thicknesses are always adjacent to each other on the same substrate. To guarantee that the measured flakes are of uniform thickness, we used a needle tip to cut the current channel connecting flakes of different thicknesses. However, this process results in Fe₃GaTe₂ nanoflakes not being an ideal Hall bar configuration, therefore, we cannot accurately calculate the resistivity and Hall resistivity of the samples. In order to preserve the flakes from degradation, the whole process of device preparation was operated in the glovebox with Ar atmosphere ($H_2O < 0.1$

ppm, $O_2 < 0.1$ ppm). Before taking the device out of the glove box, we first installed the device into a customer-designed puck (Supplementary Fig. 2b), which was sealed with vacuum grease in the glove box. Furthermore, the whole package was then immediately loaded into a commercial physical property measurement system (PPMS DynaCool, Quantum Design) within 1 min.

Experimental measurements

The magnetic properties of Fe₃GaTe₂ bulk crystals were characterized by the SQUID system (Quantum Design) equipped with a vibrating sample magnetometer (VSM) in both out-of-plane (H // c) and in-plane (H // ab) directions, and the electric transport properties were measured by a physical property measurement system (PPMS DynaCool, Quantum Design). In the measurements of hysteresis loop in MR and AHE in Fe₃GaTe₂ thin flakes, we first raised the magnetic field to +3 T (the value greater than the saturation magnetic field of Fe₃GaTe₂, direction along out-of-plane), then took the curve with the field continuously swept to -3T and back to +3 T.

Data availability

All data supporting the findings of this study are included in the paper and its Supplementary Information files. The corresponding author can also provide additional data upon reasonable request.

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Author contributions

X.H.C. conceived and coordinated the project. M.J.W. developed device fabrication techniques and performed measurements with assistance from B.L., K.J.Z., Y.Z.D. M.J.W., B.L., T.W., Z.J.X. and X.H.C. analyzed and discussed the data. M.J.W., B.L., Z.J.X. and X.H.C. wrote the manuscript. All authors discussed the results and commented on the manuscript.

Competing interests

The authors declare no competing interests.

Additional information

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